

VAKSIS

R&D AND ENGINEERING

PVD-handy® sm



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PRODUCT INFORMATION

PVD-handy sm series is a part of Vaksis PVD – handy platform which designed and manufactured for low budget projects. PVD-handy sm series is really convenient for use and easily handled as the adjective "handy" described in the dictionary which involves the techniques and combinations below:

CONFIGURATION MATRIX

Techniques	Magnetron Sputtering (MS)	Thermal Evaporation (Th E)	Organic and Metal Evaporation (OLED/OPV)
PVD-handy sm	✓	✓	✓

TECHNICAL SPECIFICATIONS

Base Pressure	≈ 2x10 ⁻⁶ Torr
Substrate Size	Max. 3" diameter
Thickness Measurement	In-situ measurement with Quartz X-tal Oscillator
Temperature Controlling System	PID method
Number of Power Sources	1
Number of Sources	Max. 2
Loading	Raised bell jar with a lift mechanism
Control	Semi-Automatic

POWER SOURCES

- DC and/or RF Power Supply for Sputtering Magnetron Source
- Effusion Cell A.C. Power Supply for Metal and/or Organic Evaporation Sources
- Power Supply for Resistive Thermal Evaporation Source

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